



IFW

PATENT
Customer No. 22,852
Attorney Docket No. 02887.0268

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
Hitoshi Ito) Group Art Unit: 2814
Serial No.: 10/802,758) Examiner: DOAN, Theresa T.
Filed: March 18, 2004) Confirmation No.: 5319
For: SEMICONDUCTOR DEVICE AND)
METHOD FOR MANUFACTURING)
THE SAME)

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

RESPONSE TO RESTRICTION REQUIREMENT

In a restriction requirement dated July 14, 2005, the period for response to which extends through August 15, 2005, (August 14, 2005, being a Sunday) the Examiner required restriction under 35 U.S.C. § 121 between Group I, claims 10-20, characterized by the Examiner as being drawn to a method for manufacturing a semiconductor device; and Group II, claims 1-9, characterized by the Examiner as being drawn to semiconductor devices. Applicant elects to prosecute Group II, claims 1-9, without traverse.

Please grant any extensions of time required to enter this response and charge any additional required fees to our deposit account 06-0916.

Respectfully submitted,

FINNEGAN, HENDERSON, FARABOW,
GARRETT & DUNNER, L.L.P.

Dated: August 11, 2005

By: Stephen L. Pitman #26,325 for
Richard V. Burgujian
Reg. No. 31,744